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IS 12308 ( Part 6 ): 1991

### भारतीय मानक

# ढलवां लोहे एवं कच्चे लोहे के रासायनिक विश्लेषण की पद्धतियाँ

भाग 6 भारात्मक पद्धति द्वारा सिलिकॉन ज्ञात करना (0·1 से 6·0 प्रतिशत सिलिकॉन के लिए)

Indian Standard

### METHODS FOR CHEMICAL ANALYSIS OF CAST IRON AND PIG IRON

PART 6 DETERMINATION OF SILICON BY GRAVIMETRIC METHOD (FOR SILICON 0·1 TO 6·0 PERCENT)

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#### **FOREWORD**

This Indian Standard (Part 6) was adopted by the Bureau of Indian Standards, after the draft finalized by the Methods of Chemical Analysis of Ferrous Metals Sectional Committee had been approved by the Metallurgical Engineering Division Council.

Chemical analysis of cast iron and pig iron was covered in IS 228: 1959 'Methods of Chemical analysis of pig iron, cast iron and plain carbon and low alloy steels (revised)'. During its second revision it was decided that a comprehensive series should be prepared for chemical analysis of all type of steels and the other covering the chemical analysis of cast iron and pig iron. Accordingly IS 228 on revision was published in several parts covering chemical analysis of various steels only and a separate series of standards under IS 12308 is being published for chemical analysis of cast iron and pig iron. This standard (Part 6) is one in the latter series. The other parts in the series are as follows:

- IS 12308 Methods for chemical analysis of cast iron and pig iron:
- Part 1 Determination of total carbon by thermal conductivity method
- Part 2 Determination of sulphur by iodimetric titration method
- Part 3 Determination of manganese by periodate spectrophotometric method
- Part 4 Determination of total carbon, graphitic carbon and combined carbon by gravimetric method
- Part 5 Determination of phosphorus by alkalimetric method (for phosphorus 0.01 to 0.50 percent)
- Part 7 Determination of nickel by dimethylglyoxime (gravimetric) method (for nickel 0.5 to 36 percent)
- Part 8 Determination of chromium by persulphate (oxidation) method (for chromium 0.1 to 28 percent)
- Part 9 Determination of molybdenum by thiocyanate (spectrophotometric) Method (for molybdenum 0'1 to 1'0 percent)
- Part 10 Determination of manganese (up to 7.0 percent) by arsenite (volumetric) method
- Part 11 Determination of total carbon by the direct combustion (volumetric) method (for carbon 1.50 to 4.50 percent)

The method given in this part for determination of silicon has been updated on the basis of experience gained during the past, while following the method of test given in 6 of IS 228: 1959 for cast iron and pig iron.

In reporting the result of a test or analysis made in accordance with this standard, if the final value, observed or calculated is to be rounded off, it shall be done in accordance with IS 2: 1960 'Rules for rounding off numerical values (revised)'.

### Indian Standard

### METHODS FOR CHEMICAL ANALYSIS OF CAST IRON AND PIG IRON

# PART 6 DETERMINATION OF SILICON BY GRAVIMETRIC METHOD (FOR SILICON 0.1 TO 6.0 PERCENT)

#### 1 SCOPE

This standard (Part 6) describes the gravimetric method for determination of silicon in the range of 0.1 to 6.0 percent in cast iron and pig iron.

#### 2 SAMPLING

The sample shall be drawn and prepared as prescribed in the relevant Indian Standard.

#### 3 QUALITY OF REAGENTS

Unless specified otherwise, analytical grade reagents and distilled water (see 1S 1070: 1977) shall be employed in the test.

### 4 DEFERMINATION OF SILICON BY GRAVIMETRIC METHOD

#### 4.1 Outline of the Method

Sample is dissolved, silicic acid is dehydrated and silica is determined after hydrofluorization.

#### 4.2 Reagents

- **4.2.1** Dilute Nitric Acid 2:3 (v/v) and 1:2 (v/v).
- **4.2.2** Dilute Hydrochloric Acid 1:1 (v/v).
- **4.2.3** Perchloric Acid 70 percent (v/v).
- **4.2.4** Tartaric Acid 20 percent (m/v).
- **4.2.5** Dilute Sulphuric Acid 20 percent (v/v).
- **4.2.6** Hydrofluoric Acid 40 percent (v/v).

#### 4.3 Procedure

4.3.1 Transfer 0.500 to 2.000 g of sample (depending upon the silicon content) to a 400-ml tall-form beaker covered with a watch glass and dissolve in 20 ml of nitric acid (2:3 see 4.2.1). When the violent reaction has ceased, add 20 ml of dilute hydrochloric acid (1:1 see 4.2.2). Heat for a minute or so. Cool and add 20 ml perchloric acid. Evaporate the solution to fumes for 15 to 20 minutes at such a rate that the perchloric acid refluxes on the sides of the beaker.

4.3.2 Cool the solution and add 100 ml of hot water (40 to 50°C), boil gently for two to three minutes till the iron salts dissolve.

NOTE — If the sample portion contains chromium (more than 100 mg) add 1 ml of tartaric acid solution for each 25 mg of chromium.

4.3.3 Add paper pulp to the solution and filter through medium textured filter paper, being careful to remove adhering particles from the beaker by rubber tipped glass rod. Wash the residue thoroughly with hot dilute hydrochloric acid (1:1) and finally with hot water (5-6 times) till free from chloride.

NOTE — Test the filtrate with 0.5 percent silver nitrate solution.

- **4.3.4** Transfer the residue and the paper in a platinum crucible. Heat at  $600^{\circ}$ C until the carbon is oxidized. Finally ignite the residue at 1 000 to 1 050°C for 30 minutes, cool in a desiccator and weigh ( $M_1$ ).
- **4.3.5** Add sufficient dilute sulphuric acid (see **4.2.5**) to moisten the residue and then add 5 to 10 ml of hydrofluoric acid. Evaporate to dryness and then heat gradually until sulphuric acid is removed. Ignite at 1 000 to 1 050°C for 5 to 10 minutes, cool in a desiccator and weigh ( $M_2$ ).
- 4.3.6 Carry out a blank determination, following the same procedure as specified in 4.3.1 to 4.3.5 and using the same amount of reagents.

#### 4.4 Calculation

Silicon, percent by mass 
$$= \frac{(A - B) \times 46.72}{C}$$

where

- $A = (M_1 M_2) = \text{mass}$ , in g, of silica obtained from the sample,
- B = mass, in g, of silica obtained from the blank, and
- C = mass, in g, of sample taken.

#### 4.5 Reproducibility

 $\pm 0.002$  at 0.2 percent Silicon,

 $\pm 0.01$  at 4 percent Silicon, and

 $\pm 0.02$  at 6 percent Silicon.

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